

Example- For silicon at 300 K, we have an acceptor concentration of $1 \times 10^{17} \text{ \#/cm}^3$. We wish to add donors to make an ***n*-type** (use phosphorous) compensated semiconductor with a conductivity of $20 \text{ S/cm} = 2000 \text{ S/m}$, i.e., determine N_d .

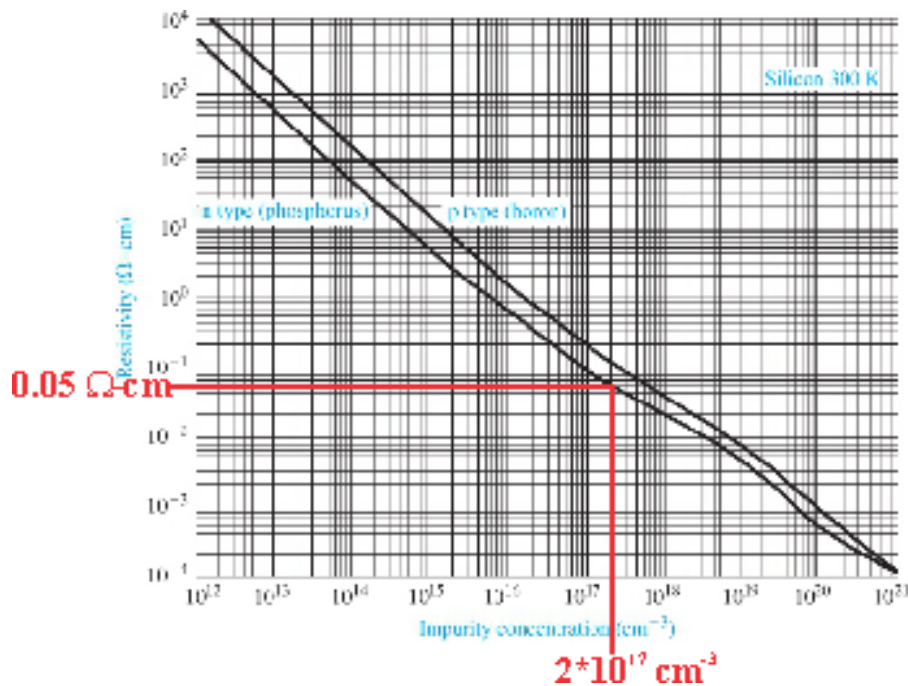
Known- $T = 300 \text{ K}$, $N_a = 1 \times 10^{17} \text{ \#/cm}^3$, and $\sigma = 20 \text{ S/cm} = 2000 \text{ S/m}$.

Per (5.20), the resistivity is $\rho = 1/\sigma = 1/20 = 0.05 \text{ \Omega}\cdot\text{cm}$.

Using (5.23), $\sigma = e(\mu_n n + \mu_p p)$.

Assume intrinsic charge concentration, $n_i = 1.5 \times 10^{10} \text{ \#/cm}^3$ (Table B.4) is negligible compared to N_a and N_d , and that the net negative charge concentration is $n \approx N_d - N_a$ having mobility μ_n . This gives $\sigma \approx e \mu_n (N_d - N_a) = (1.6022 \cdot 10^{-19} \text{ C}) \mu_n (N_d - 10^{17} \text{ cm}^{-3})$.

Using $\rho = 0.05 \text{ \Omega}\cdot\text{cm}$ and Figure 5.4a, we read that the impurity concentration for *n*-type (phosphorous) should be **$2 \times 10^{17} \text{ \#/cm}^3$**



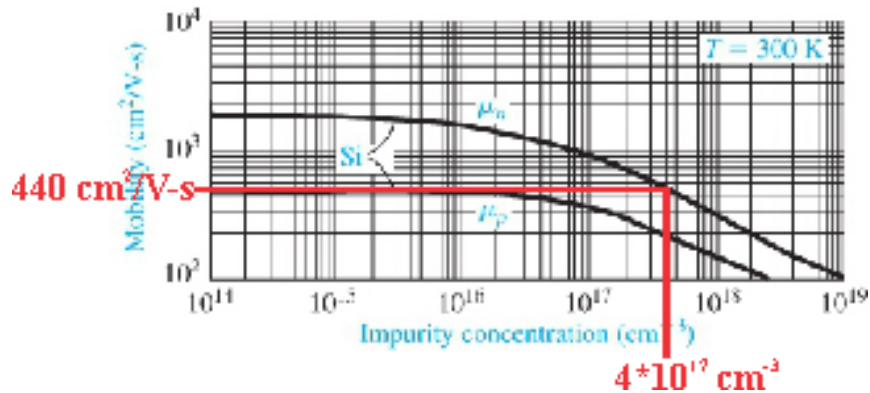
From *Semiconductor Physics and Devices: Basic Principles* (4th Edition), Donald A. Neamen, McGraw Hill, 2012, ISBN 978-0-07-352958-5.

$$\text{Letting } 2 \times 10^{17} \text{ \#/cm}^3 = N_d - N_a = N_d - 10^{17} \text{ \#/cm}^3 \Rightarrow \underline{N_d = 3 \times 10^{17} \text{ \#/cm}^3}.$$

The overall ionized impurity concentration is then

$$N_I = N_d^+ + N_a^- = 3 \times 10^{17} + 10^{17} \Rightarrow \underline{N_I = 4 \times 10^{17} \text{ \#/cm}^3}.$$

Going to Figure 5.3 (middle graph for silicon), we can read what the electron mobility should be for this impurity concentration. This yields $\mu_n \approx 440 \text{ cm}^2/\text{V}\cdot\text{s}$.



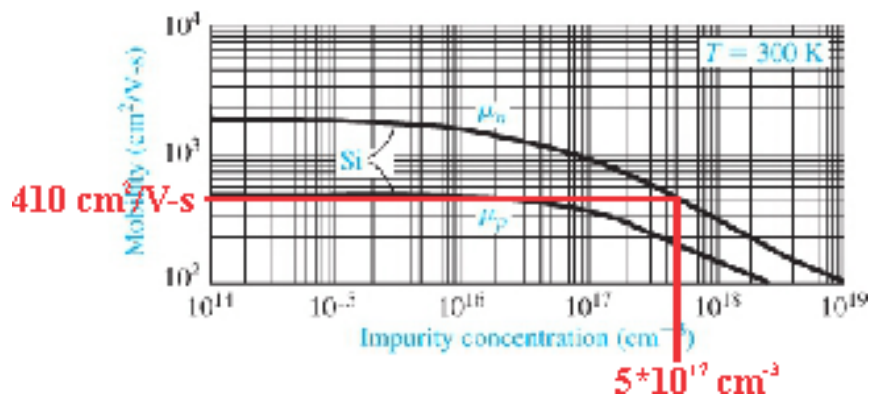
This gives $\sigma \approx e \mu_n (N_d - N_a) = (1.6022 \cdot 10^{-19})(440)(3 \cdot 10^{17} - 10^{17}) \Rightarrow \sigma \approx 14.1 \text{ S/cm}$ and $\rho = 0.07 \text{ }\Omega\cdot\text{cm}$. A bit low for σ and a bit high for ρ . Looking at Figure 5.4a, we see that increasing the impurity concentration (and hence N_d) decreases the resistivity.

For a second try, let's bump the donor concentration up by the ratio of resistivities

$$0.07/0.05 \cdot 3 \times 10^{17} \text{ \#/cm}^3 = 4.2 \times 10^{17} \text{ \#/cm}^3 \Rightarrow N_d = 4 \times 10^{17} \text{ \#/cm}^3 \text{ (second try).}$$

The overall ionized impurity concentration is then $4 \times 10^{17} + 10^{17} \Rightarrow N_I = 5 \times 10^{17} \text{ \#/cm}^3$.

Going back to Figure 5.3 w/ our new N_I , we read $\mu_n \approx 410 \text{ cm}^2/\text{V}\cdot\text{s}$.



So $N_d = 4 \times 10^{17} \text{ \#/cm}^3$ gives

$$\sigma \approx e \mu_n (N_d - N_a) = (1.6022 \cdot 10^{-19})(410)(4 \cdot 10^{17} - 10^{17})$$

$$\Rightarrow \underline{\underline{\sigma = 19.7 \text{ S/cm}}} \text{ \& } \underline{\underline{\rho = 0.051 \text{ }\Omega\cdot\text{cm}}}$$

Given graphical accuracy, this solution is acceptable (1.5% error).